

213313US-0X



IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF :  
KUNIHICO TERASE ET AL : EXAMINER: UHLIR, N.  
SERIAL NO: 09/939,804 :  
FILED: AUGUST 28, 2001 : GROUP ART UNIT: 1773  
FOR: FLOOR POLISHING  
COMPOSITION

AMENDMENT

ASSISTANT COMMISSIONER FOR PATENTS  
WASHINGTON, D.C. 20231

SIR:

Responsive to the Office Action dated May 21, 2002, Applicants respectfully request reconsideration of the above-identified application in view of the following amendment and remarks.

IN THE CLAIMS

Please cancel Claims 1 and 2.

Please amend Claim 3 as follows:

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3. (Amended) A floor polishing composition containing a film-formable organic resin material as the main component, which further contains at least scaly particles, wherein the scaly particles are silica corresponding to layered polysilicic acid, wherein the layered polysilicic acid is scaly silica particles having particle structures of layered structures present independently to each other, which comprises foliar silica secondary particles wherein a

sub B1  
[Handwritten notes and signatures]